liquid filters

• polytetrafluoroethylene (PTFE)



FLUOROFLOW pleated filter cartridges feature an all-Fluoropolymer construction that provides excellent chemical resistance in filtration of acids, bases and solvents.

FLUOROFLOW filters fit in standard filter housings and are available in a variety of filter ratings, lengths and end fittings for maximum versatility. The all flouropolymer construction provides excellent chemical resistance for the most aggressive applications up to 150°C (302°F).

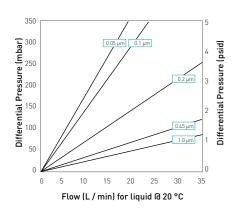
FLUOROFLOW filters are available flushed with ozonated UPW to further minimise extractables or wet-packed to eliminate on-site wetting for use in aqueous applications.

Features and Benefits

- Chemical resistance process capability and compatibility
- Wet-packed option eliminates lengthy wetting procedure and minimises equipment downtime
- All filters are 100% integrity tested to assure reliable product performance
- Available in 0.05 to 100 microns



Performance Characteristics



10" Size (250 mm) Cartridge

Specifications

Materials of Construction

■ Filtration Membrane: Polytetrafluoroethylene (PTFE) Polytetrafluoroethylene ■ Upstream Support:

(PTFE) ■ Downstream Support: Polytetrafluoroethylene

(PTFE) ■ Inner Support Core: PFA Outer Protection Cage: PFΔ ■ End Caps: PFA

■ Standard o-rings: FEP Encapsulated Silicone

Effective Filtration Area (EFA)

10" (250 mm) 0.63 m² (6.8 ft²)

Recommended Operating Conditions

Temperature		Max. Forward dP			
°C	°F	(bar)	(psid)		
24	75	5.5	80.0		
75	167	3.8	55.0		
125	257	2.0	30.0		
150	302	1.0	15.0		

Particle Shedding

Wet-packed <2 particles / ml >0.2µm after 26.5L @ 3.8L / min

Dry-packed <2 particles / ml >0.2µm after 26.5L @ 3.8L / min

Metals Extractables

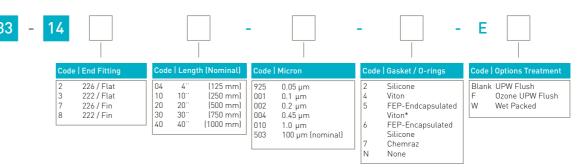
<20ppb (total) in a 10% HN03 extraction of 1.5 litres for 24 hours at ambient temperatures.

Micron Rating		0.05	0.10	0.20	0.45	1.00				
Bubble Point (60 / 40 IPA/Water at 25°C)										
Min. Bubble Point	(barg)	2.8	1.5	0.9	0.5	0.2				
	(psig)	40.6	21.7	13.0	7.2	2.9				

Applications

- Aggressive acids, bases and solvents
- Photolithography chemicalsOzonated and / or hot UPW

Ordering Information



Lenntech by

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